

UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/658,501	09/08/2000	Yasuhiko Kojima	PM 273851 EL00018CDC	3068
909	7590 01/18/2006		EXAMINER	
PILLSBURY WINTHROP SHAW PITTMAN, LLP			MOORE, KARLA A	
P.O. BOX 1 MCLEAN,	•		ART UNIT	PAPER NUMBER
,			1763	
			DATE MAILED: 01/18/2006	5

Please find below and/or attached an Office communication concerning this application or proceeding.

				ið			
Office Action Summary		Application No.	Applicant(s)				
		09/658,501	KOJIMA ET AL.				
		Examiner	Art Unit				
		Karla Moore	1763				
Period fo	The MAILING DATE of this communication apor Reply	ppears on the cover sheet	with the correspondence address -				
WHIC - Exte after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPLICATION OF THE MAILING INSTANTAL OF TH	DATE OF THIS COMMUN. 136(a). In no event, however, may d will apply and will expire SIX (6) Mote, cause the application to become	IICATION. a reply be timely filed ONTHS from the mailing date of this communication. ABANDONED (35 U.S.C. § 133).				
Status							
1)⊠	Responsive to communication(s) filed on 23 L	December 2004.					
2a) <u></u> ☐	This action is FINAL . 2b)⊠ Thi	is action is non-final.					
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
	closed in accordance with the practice under	Ex parte Quayle, 1935 C	D. 11, 453 O.G. 213.				
Disposit	ion of Claims						
4)⊠	Claim(s) 1-23 is/are pending in the application	n.					
-	4a) Of the above claim(s) is/are withdrawn from consideration.						
5)[Claim(s) is/are allowed.						
6)⊠	Claim(s) 1-23 is/are rejected.						
7)	Claim(s) is/are objected to.						
8)[Claim(s) are subject to restriction and/	or election requirement.					
Applicat	ion Papers		·				
9)[The specification is objected to by the Examin	ner.					
10)🛛	The drawing(s) filed on <u>08 September 2000</u> is	s/are: a)⊠ accepted or b	objected to by the Examiner.				
	Applicant may not request that any objection to the	e drawing(s) be held in abey	ance. See 37 CFR 1.85(a).				
	Replacement drawing sheet(s) including the corre-	ction is required if the drawir	g(s) is objected to. See 37 CFR 1.121(d).				
11)	The oath or declaration is objected to by the E	Examiner. Note the attach	ed Office Action or form PTO-152.				
Priority (under 35 U.S.C. § 119						
а)	Acknowledgment is made of a claim for foreig All b) Some * c) None of: 1. Certified copies of the priority documer 2. Certified copies of the priority documer 3. Copies of the certified copies of the priority application from the International Burea See the attached detailed Office action for a list	nts have been received. Its have been received in ority documents have been au (PCT Rule 17.2(a)).	Application No In received in this National Stage				
2) Notice 3) Infor	ot (s) De of References Cited (PTO-892) De of Draftsperson's Patent Drawing Review (PTO-948) The mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08 Tear No(s)/Mail Date 19900.	Paper N	v Summary (PTO-413) o(s)/Mail Date f Informal Patent Application (PTO-152) 				

Art Unit: 1763

DETAILED ACTION

Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 24 February 2003 has been entered.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 3. Claims 1-5, 8-12, 15-16 and 21-23 are rejected under 35 U.S.C. 102(b) as being anticipated by U.S. Patent No. 5,440,887 to Nishizato et al.
- 4. Nishizato et al. disclose a vaporizer which vaporizes a liquid material under a depressurized atmosphere, the vaporizer comprising: a liquid storing chamber (Figures 2 and 3, 6) temporarily storing the liquid material therein; a vaporizing chamber (13) set in the depressurized atmosphere; a small aperture (23) connecting between the liquid storing chamber and the vaporizing chamber so as to supply the liquid material to the vaporizing chamber; a valve body (7a) located on a side of said small aperture away from said vaporizing chamber so as to open and close an inlet port (in Figures 2 and 3, the inlet port is at the bottom part of structure 23) of said small aperture, said inlet port being located toward the liquid storing chamber; and an actuator (7b) controlling a degree of opening in the valve body, wherein said valve body is located outside the vaporizing chamber to permit an uninhibited flow of the liquid material, thereby achieving a smooth flow of vapor of the liquid material.

Art Unit: 1763

5. With respect to claim 2, Nishizato et al. further comprises carrier gas introducing means (Figure 3, 14) for introducing a carrier gas into the vaporizing chamber.

- 6. With respect to claim 3, the carrier gas introducing means injects the carrier gas in the vicinity of an outlet port (in Figures 3 and 5, the outlet port is at the top part of structure 23) of the small aperture.
- 7. With respect to claims 4 and 5, the carrier gas introducing means includes an injecting port positioned in the vicinity of the outlet port of the small aperture so as to inject the carrier gas from a surrounding area of the outlet port in a direction substantially perpendicular/substantially opposite of a flow of the liquid material from said inlet port to said outlet port of said small aperture. See Figures 3 and 5.
- 8. With respect to claim 8, a direction of a flow of the liquid material from said inlet port to said outlet port of said small aperture coincides with a direction of an exit of the vaporizing chamber. See Figures 2-3 and 5.
- 9. With respect to claim 9, the vaporizer further comprises a heater (Figure 4, 42) provided in a periphery of the vaporizing chamber and a temperature sensor (Figure 4, 41) detecting a temperature of the periphery of the vaporizing chamber. Also, see column 4, rows 45-57.
- 10. With respect to claim 10, the vaporizer further comprises a heater (Figure 4, 42) provide near the liquid storing chamber for heating the liquid material in the liquid storing chamber and a temperature sensor (Figure 4, 41) positioned in the vicinity of an outlet port of the small aperture. Also, see column 4, rows 45-57.
- 11. With respect to claim 11, which is a drawn to a material to be used during an intended method using the apparatus, the courts have ruled that expressions relating the apparatus to contents thereof during an intended operation are of no significance in determining patentability of the apparatus claim. Exparte Thibault, 164 USPQ 666, 667 (Bd. App. 1969).
- 12. With respect to claim 15, a diameter of said small aperture is equal to or less than 2mm (column 6, rows 24-27).
- 13. With respect to claim 16, a diameter of said small aperture falls within a range of from 0.5 to 2 mm.

Application/Control Number: 09/658,501

Art Unit: 1763

Page 4

- 14. With respect to claim 12, Nishizato et al. also disclose a semiconductor manufacturing system comprising: a process apparatus (Figure 1A, 50) performing a process using a vaporized material; and a vaporizer which vaporizes a liquid material under a depressurized atmosphere so as to generate the vaporized material, the vaporizer comprising: a liquid storing chamber (Figures 2 and 3, 6) temporarily storing the liquid material therein; a vaporizing chamber (13) set in the depressurized atmosphere; a small aperture (23) connecting between the liquid storing chamber and the vaporizing chamber so as to supply the liquid material to the vaporizing chamber; a valve body (7a) located on a side of said small aperture away from said vaporizing chamber so as to open and close an inlet port (in Figures 2 and 3, the inlet port is at the bottom part of structure 23) of said small aperture, said inlet port being located toward the liquid storing chamber; and an actuator (7b) controlling a degree of opening in the valve body, wherein said valve body is located outside the vaporizing chamber to permit an uninhibited flow of the liquid material, thereby achieving a smooth flow of vapor of the liquid material.
- 15. With respect to claim 21, the vaporizer further comprises carrier gas introducing means (Figures 3 and 5, 14) for introducing a carrier gas into the vaporizing chamber, wherein the carrier gas introducing means injects the carrier gas in the vicinity of an outlet port of the small aperture, and a direction of the carrier gas is different from a direction from the inlet port to the outlet port of said small aperture (see Figures 3 and 5).
- 16. With respect to claim 22, Nishizato et al. further disclose a vaporizer which vaporizes a liquid material under a depressurized atmosphere, the vaporizer comprising: a liquid storing chamber (Figures 2 and 3, 6) temporarily storing the liquid material therein; a vaporizing chamber (13) set in the depressurized atmosphere; a small aperture (23) connecting between the liquid storing chamber and the vaporizing chamber so as to supply the liquid material to the vaporizing chamber; a valve body (7a) located on a side of the liquid storing chamber with respect to said small aperture so as to open and close an inlet port (in Figures 2 and 3, the inlet port is at the bottom part of structure 23) of said small aperture which opens in the liquid storing chamber and also to control an amount of the liquid material being

Art Unit: 1763

supplied to said vaporizing chamber by controlling a degree of opening of the inlet port of said small aperture; and an actuator (7b) controlling a degree of opening of the valve body.

17. With respect to claim 23, Nishizato et al. also disclose a semiconductor manufacturing system comprising: a process apparatus (50) performing a process using a vaporized material; and a vaporizer which vaporizes a liquid material under a depressurized atmosphere so as to generate the vaporized material, the vaporizer comprising: a liquid storing chamber (Figures 2 and 3, 6) temporarily storing the liquid material therein; a vaporizing chamber (13) set in the depressurized atmosphere; a small aperture (23) connecting between the liquid storing chamber and the vaporizing chamber so as to supply the liquid material to the vaporizing chamber; a valve body (7a) located on a side of the liquid storing chamber with respect to said small aperture so as to open and close an inlet port (in Figures 2 and 3, the inlet port is at the bottom part of structure 23) of said small aperture which opens in the liquid storing chamber and also to control an amount of the liquid material being supplied to said vaporizing chamber by controlling a degree of opening of the inlet port of said small aperture; and an actuator (7b) controlling a degree of opening of the valve body.

Claim Rejections - 35 USC § 103

- 18. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 19. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary.

 Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the

examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

- 20. Claim 6 is rejected under 35 U.S.C. 103(a) as being unpatentable over Nishizato et al. as applied to claims 1-5, 8-12, 15-16 and 21-23 above, in view of U.S. Patent No. 6,224,681 to Sivaramakrishnan et al.
- 21. Nishizato et al. disclose the invention substantially as claimed and as described above.
- 22. However, Nishizato et al. fail to teach the valve body formed by one of a diaphragm and a bellows.
- 23. Sivaramakrishnan et al. teach the use of a valve body comprising one of a diaphragm or a bellows for the purpose of controlling liquid flow (column 3, row 60 through column 4, row 6).
- 24. It would have been obvious to one of ordinary skill in the art at the time the Applicant's invention was made to have provided a valve body comprising one of a diaphragm and a bellows for the purpose controlling liquid flow as taught by Sivaramakrishnan et al.
- 25. Claims 7 and 20 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nishizato et al. as applied to claims 1-5, 8-12, 15-16 and 21-23 above, in view of U.S. Patent No. 5,776,254 to Yuuki et al.
- 26. Nishizato et al. disclose the invention substantially as claimed and as described above.
- 27. However, with respect to claim 7, Nishizato et al. fail to teach the vaporizing chamber having a conical shape so that a cross section of the vaporizing chamber increases as a distance from the small aperture increases.
- 28. With respect to claim 20, the central axis of said vaporizing chamber coincides with a direction from the inlet port to an outlet port of said small aperture. However, Nishizato fail to teach the vaporizing chamber having a conical shape so that a cross section of the vaporizing chamber increases as a distance from the small aperture increases.
- 29. Yuuki et al. teach the use of a vaporizing chamber having a conical shape so that a cross section of the vaporizing chamber increases as a distance from the small aperture increases for the purpose of

Art Unit: 1763

quickly and effectively vaporizing particles supplied to the vaporizer so that liquid material does not stagnate in piping (Figure 7, 4; column 15, rows 10-16).

- 30. It would have been obvious to one of ordinary skill in the art at the time the Applicant's invention was made to have provided as taught by Yuuki et al.
- 31. Claims 13-14 and 18-19 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nishizato et al. as applied to claims 1-5, 8-12, 15-16 and 21-23 above, in view of U.S. Patent No. 4,847,469 to Hofmann et al.
- 32. Nishizato et al. disclose the invention substantially as claimed and as described above.
- 33. However, Nishizato et al. fail to disclose the exact dimensions of the vaporizing chamber, as recited in claims 13-14 and 18-19.
- 34. Hofmann et al. teach that the sizing of a vaporization chamber for supplying a processing gas to a deposition chamber is scalable based on the size of the deposition chamber (column 6, rows 5-11).
- 35. It would have been obvious to one of ordinary skill in the art at the time the Applicant's invention was made to have provided a vaporizing chamber with appropriately scaled dimensions as dictated by the deposition chamber to which it is supplying a processing gas as taught by Hofmann.
- 36. Examiner also notes that the courts have ruled that where the only difference between the prior art and the claims is a recitation of relative dimensions of the claimed device and a device having the claimed relative dimensions would not perform differently than the prior art device, the claimed device is not patentably distinct from the prior art device. <u>In Gardner v. TEC Systems, Inc.</u>, 725 F.2d 1338, 220 USPQ 777 (Fed. Cir. 1984), cert. denied, 469 U.S. 830, 225 USPQ 232 (1984).
- 37. Claim 17 is rejected under 35 U.S.C. 103(a) as being unpatentable over Nishizato et al.
- 38. Nishizato et al. disclose the invention substantially as claimed and as described above.
- 39. However, Nishizato et al. fails to explicitly teach a length of said small aperture is equal to or less than 5 mm.

Art Unit: 1763

40. Nishizato et al. do however clearly teach that the dimensions of the small aperture are minimized in an effort to reduce the volume of the aperture so that the amount of bubble produced is also reduced (column 6, rows 18-30.

- 41. The courts have ruled that where the general conditions of a claim are disclosed in the prior art, it is not inventive to discover the optimum or workable ranges by routine experimentation. <u>In re Aller</u>, 220 F.2d 454, 456, 105 USPQ 233, 235 (CCPA 1955).
- 42. It would have been obvious to one or ordinary skill in the art at the time the Applicant's invention was made to have provided an aperture with further minimized dimensions as suggested in Nishizato et al. in order to reduce the amount of bubbles produced as taught by Nishizato et al.

Response to Arguments

43. Applicant's arguments with respect to claim 1-23 have been considered but are moot in view of the new ground(s) of rejection. In some cases, the rejections have been restructured using previously relied upon prior art to account for the amendments. While in other instances, new art is relied upon to address new limitations.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Karla Moore whose telephone number is 571.272.1440. The examiner can normally be reached on Monday-Friday, 9:00 am-6:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on 571.272.1435. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Art Unit: 1763

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Karla Moore Patent Examiner Art Unit 1763

13 January 2006